

APPLICATION No.
09/695,253

INFORMATION DISCLOSURE STATEMENT BY APPLICANT

APPLICANT
Hang-woo LEE et al.
FILING DATE
October 25, 2000

GROUP 2879

U.S. PATENT DOCUMENTS

[illegible]

FOREIGN PATENT DOCUMENTS

Examiner Initials	Foreign Patent Document		Country	Date of Publication (MM-DD-YYYY)	Translation	
	Number	Kind Code (if known)			Yes	no
MA	2 330 687	A	UK	04/28/1999		X
MA	1 303 800		GB	01/17/1973		Y
MA	WO 96/42101		PCT	12/27/1996		Y
MA	9-11536		JP (partial translation)	09/14/1997		Y
MA	0 838 831	A2	EP			

NON PATENT LITERATURE DOCUMENTS

Examiner Initials	Include name of author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.		
Examiner Signature	an Day	Date Considered	10/4/02

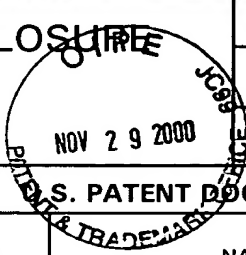
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INFORMATION DISCLOSURE CITATION

PTO-1449

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EXAMINER'S INITIALS	PATENT NO.	DATE	NAME	CLASS	SUBCLASS	FILING DATE
MW	5,773,834	6/30/98	YAMAMOTO et al.	250	423F	—

FOREIGN PATENT DOCUMENTS

EXAMINER'S INITIALS	PATENT NO.	DATE	COUNTRY	CLASS	SUBCLASS	Translation	
						Yes	No

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

MW	Masako YUDASAKA, "Specific conditions for Ni catalyzed carbon nanotube growth by chemical vapor deposition", Appl. Phys. Lett. 67 (17), October 23, 1995, pages 2477-2479
MW	Kazuhiro YAMAMOTO, "New method of carbon nanotube growth by ion beam irradiation", Appl. Phys. Lett. 69 (27), December 30, 1996, pages 4174-4175
MW	L. C. QIN, "Growing carbon nanotubes by microwave plasma-enhanced chemical vapor deposition", Appl. Phys. Lett. Vol. 72, No. 26, June 29, 1998, pages 3437-3439

EXAMINER M. Day	DATE CONSIDERED 10/4/02
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EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.